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## Усиленное оптическое пропускание в голографических и поликристаллических наноструктурах = Extraordinary optical transmission in holographic and polycrystalline structures : Extraordinary optical transmission in holographic and polycrystalline structures : диссертация ... кандидата физико-математических наук : 01.04.03 / Ушков Андрей Александрович; [Место защиты: ФГАОУ ВО «Московский физико-технический институт (национальный исследовательский университет)»]. - Долгопрудный, 2021. - 199 с. : ил.

## Оглавление диссертациикандидат наук Ушков Андрей Александрович

Contents

Page

1. Introduction

Historical overview

Extraordinary optical transmission

EOT through subwavelength apertures

EOT through continuous metal films

Top-down and bottom-up fabrication approaches for EOT devices

Outline and objective of the thesis

2. Theory of Surface Plasmon Polaritons

2.1 Introduction

2.2 Scattering matrix theory

2.3 Eigenmodes calculation via scattering matrix

2.4 Electromagnetic modes in multilayer plane-parallel structures

2.4.1 Simulation algorithm

2.4.2 Metal-dielectric interface

2.4.3 Thin metal film

2.4.4 Waveguide on the metallic substrate

2.4.5 Fabry-Perot resonator

2.5 Conclusion

3. Theory of Diffraction Gratings

3.1 Introduction

3.2 Diffraction orders and Ewald's sphere

3.3 Numerical methods for gratings simulation

3.3.1 Introduction

3.3.2 Rigorous Coupled Wave Analysis

3.3.3 C-method

3.3.4 Generalized Source Method

3.4 Conclusion

4. Fabrication Methods

4.1 Introduction

4.2 Layer deposition methods

4.2.1 Spin coating

4.2.2 Magnetron sputtering

4.3 Methods of surface nanostructuring

4.3.1 Laser Interference Lithography

4.3.2 Colloidal Self-Assembly

4.4 Simulation of the resist development process

4.4.1 Isotropic development process

4.4.2 Simulations for Laser Interference Lithography

4.4.3 Simulations for Nanosphere Photolithography

4.5 Conclusion

5. Variable Depth Gratings

5.1 Introduction

5.2 Fabrication techniques for variable depth gratings

5.2.1 Resist reflow

5.2.2 Moving edge/slit

5.2.3 Moire patterns in the resist

5.3 Experimental observation of moire patterns

5.3.1 Two LIL exposures

5.3.2 Four LIL exposures

5.4 Conclusion

6. Transmission in Plasmonic Nanostructures

6.1 Introduction

6.2 Transmission through 1D gratings of constant depth

6.3 Transmission through 2D gratings of constant depth

6.3.1 Rectangular lattice

6.3.2 Hexagonal lattice

6.4 Transmission through 1D variable depth gratings

6.4.1 Introduction

6.4.2 Existence of optimal grating depth

6.4.3 Structure-induced color

6.5 Transmission through hexagonal nanohole arrays

6.5.1 Introduction

6.5.2 EOT in colloidal gratings with low and high disorder

6.5.3 Modelling of grating disorder via inverse space approach

6.5.4 Statistical study of polycrystalline structures

6.5.5 Depth-resolved EOT in colloidal gratings

6.6 Conclusion

Conclusion

References

List of figures

List of tables